

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.usplo.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/504,782	02/15/2000	Masahiro Kume	0819-337	8307	
22204	7590 12/16/2004	EXAMINER			
NIXON PEABODY, LLP 401 9TH STREET, NW			FLORES RUIZ, DELMA R		
SUITE 900			ART UNIT	PAPER NUMBER	
WASHINGTO	ON, DC 20004-2128	2828			
			DATE MAIL ED: 12/16/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

					M		
		Applicati	on No.	Applicant(s)			
Office Action Summary		09/504,7	82	KUME ET AL.			
		Examine	r	Art Unit			
			. Flores Ruiz	2828			
T Period for R	he MAILING DATE of this communica eply	tion appears on th	e cover sheet with	the correspondence addre	ess		
THE MA - Extension after SIX (- If the peric - If NO peric - Failure to Any reply	TENED STATUTORY PERIOD FOR LING DATE OF THIS COMMUNICAS of time may be available under the provisions of 3 (6) MONTHS from the mailing date of this communion of or reply specified above is less than thirty (30) do do for reply is specified above, the maximum statute reply within the set or extended period for reply will received by the Office later than three months after term adjustment. See 37 CFR 1.704(b).	ATION. TOFR 1.136(a). In no evecation. ays, a reply within the statory period will apply and w, by statute, cause the app	ent, however, may a reply utory minimum of thirty (3 ill expire SIX (6) MONTHS dication to become ABANI	be timely filed 0) days will be considered timely. 6 from the mailing date of this comm DONED (35 U.S.C. § 133).	nunication.		
Status							
1)⊠ Re	sponsive to communication(s) filed	on <u>12 August 200</u> 4	<u>!</u> .				
2a) Th	This action is FINAL. 2b) This action is non-final.						
•—	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition	of Claims						
4a) 5)⊠ Cla 6)⊠ Cla 7)□ Cla	aim(s) <u>1-6</u> is/are pending in the application of the above claim(s) <u>7-30</u> is/are what aim(s) <u>4-6</u> is/are allowed. aim(s) <u>1-3</u> is/are rejected. aim(s) is/are objected to. aim(s) are subject to restriction	ithdrawn from cons					
Application	Papers						
10)∏ The Ap _l Re _l	e specification is objected to by the E e drawing(s) filed on is/are: a plicant may not request that any objection placement drawing sheet(s) including the e oath or declaration is objected to be) accepted or b) on to the drawing(s) be e correction is requir	oe held in abeyance ed if the drawing(s)	See 37 CFR 1.85(a). is objected to. See 37 CFR	` '		
Priority und	er 35 U.S.C. § 119						
12)	nowledgment is made of a claim for Ill b)☐ Some * c)☐ None of: ☐ Certified copies of the priority do	cuments have bee cuments have bee the priority docume I Bureau (PCT Rul	en received. en received in App ents have been red e 17.2(a)).	lication No ceived in this National Sta	age		
2) Notice of 3) Information	References Cited (PTO-892) Draftsperson's Patent Drawing Review (PTO on Disclosure Statement(s) (PTO-1449 or PTO (s)/Mail Date		_	mary (PTO-413) lail Date mal Patent Application (PTO-15	52)		

DETAILED ACTION

Response to Amendment

Applicant's request for reconsideration of the finality of the rejection of the last Office action is persuasive and, therefore, the finality of that action is withdrawn.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1 – 3 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sverdlov (6,455,337) in view of Jung, W G et al. (KR 2002000898 A).

Regarding claims 1 – 3, Sverdlov discloses a semiconductor laser device comprising; a first cladding (see Fig. 1, Character 16) layer, which is mace of a nitride semiconductor of a first conductivity type (see Fig. 1, Character 18) and is formed over

a substrate (see Fig. 1, Character 12); an active layer (see Fig. 1, Character 20), which is mode of, which is made In_v Ga_{1-v}N layer and is formed over the first cladding layer; and a second cladding (see Fig. 1, Character 24) layer, which is made of still another nitride semiconductor of a second conductivity type (see Fig. 1, Character 22) and is formed over the active layer (see Figs. 1 – 7, Abstract, Column 2, lines 43 – 67, Column 4, lines 11 - 65). The $ln_xGa_{1-x}N$ layer and is formed in contact with the first cladding layer and substrate (see Figs. 1 – 7, Abstract, Column 2, lines 43 – 67, Column 4, lines 11 – 65). Jung W G teaches providing his device with a wherein In_x Ga_{1-x}N layer of the first conductivity type is formed between the substrate and the first cladding layer and $x \ge y$ in the composition on In with semiconductor device for the purpose of conductive a specific area and provided to easily grow an indium-containing compound layer like an In_xAl_yGa_{1-x-y}N layer, by growing In_xGa_{1-x}N as a buffer layer so that mole density of indium is easily increased or decreased. It would have been obvious at the time of applicant's invention, to combine Jung W G of teaching a Inx Ga1-xN layer of the first conductivity type is formed between the substrate and the first cladding layer and x ≥ y in the composition on In with semiconductor device because It would have been obvious to one having ordinary skill in the art at the time the invention was made to Inv Ga_{1-x}N layer of the first conductivity type is formed between the substrate and the first cladding layer and $x \ge y$ in the composition on In, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. In re Leshin, 125 USPQ 416.

Page 4

The following is an examiner's statement of reasons for allowance: claim 4 has been allowed over the prior art because they fail to teach a semiconductor laser device comprising; a first cladding layer, which is made of a nitride semiconductor of a first conductivity type and is formed over substrate; an active layer, which is made of In_yGa_1 .

yN and is formed over the first cladding layer; a second cladding layer, which is made of still another nitride semiconductor of a second conductivity type and is formed over the active; an electrode formed over the second cladding layer, and an $In_xGa_{1-x}N$ of the first conductivity type is formed between the second cladding layer and electrode, wherein 0 < x < 1, 0 < y < 1 and x > y in the composition of In.

Claims 5 – 6 has been found allowable due to their dependency on claim 4.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reason for Allowance".

Response to Arguments

Applicant's arguments filed 08/12/2004 have been fully considered but they are not persuasive. The amendment filed on 7/12/2002 canceling all claims drawn to the elected invention and presenting only claims drawn to a non-elected invention is nonresponsive (MPEP § 821.03). The remaining claims are not readable on the elected invention because have a different embodiments.

Applicant argues the prior art lacks: In claims 1 – 3, the Applicant's Amendment does not state or assert that Sverdlov '337 does not teach this "0 < x < 1, 0 < y < 1" feature. Accordingly, since the new ground of rejection relying upon thee Jung et al. The examiner disagree with the applicant arguments since the prior art does teach Sverdlov (6,455,337) in view of Jung, W G et al. (KR 2002000898 A) (see Fig. 1 in Jung, W G et al. (KR 2002000898 A)) as stated in the rejection above.

Applicant argues the prior art lacks: As discussed at length in the Amendment of October 31, 2003, the Sverdlov '337 patent does not teach or suggest the presence of an In_xGa_{l-x}N layer between the n⁺ GaN cladding layer 16 and the substrate 12, but the patentees instead disclose the presence of a buffer GaN layer between the n+ Gm cladding layer 16 and the substrate 12. Further, the Sverdlov reference does not teach or suggest the x > y relationship of the content of "In" in the buffer layer or active layer

as presently claimed (or as claimed in the earlier Amendment of October 3 1, 2003). Additionally, a review of the Jung G al reference cited by the Examiner does not reveal any explicit teaching of a relationship i.e. "x > y", between the "In" content of the In_xGa_{l-} _xN buffer laver 12 and the active laver 15 (which is also of the formula In_xGa_{l-x}N) as presently claimed. It is further noted that layers 13 and 14 of Jung et are composed of In_xAl_yGa_{l-x-y}N and are not active layer. Further, the claimed relationship of "In" in the buffers layer to the "In" in active layer, i.e., "x > y" does not appear to be implicitly suggested by any of the teachings of Jung et al. Therefore, the teachings of Jung et al. do not remedy the teaching of Sverdlov such that each and every feature of the present claim 1 is taught or suggested by the reference. The examiner disagree with the applicant arguments since the prior art does teach of a relationship i.e. "x > y", between the "In" content of the In_xGa_{l-x}N buffer laver 12 (as presently claimed (see Fig. 1 in Jung, W G et al. (KR 2002000898 A)) and the active laver 15 (which is also of the formula In_xGa_{l-x}N) as presently claimed (active layer (Sverdlov '337, see Figs. 1 – 7, Abstract, Column 2, lines 43 – 67, Column 4, lines 11 – 65 and In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., the active laver 15 (which is also of the formula In_xGa_{1-x}N) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See In re Van Geuns, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993)) as stated in the rejection above.

In response to applicant's argument that there is no suggestion to combine the references, the examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See *In re Fine*, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988)and *In re Jones*, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case,

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Delma R. Flores Ruiz whose telephone number is (571) 272-1940. The examiner can normally be reached on M - F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Min Sun Harvey can be reached on (571) -272-1835. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Delma R. Flores I Examiner

Art Unit 2828

DRFR/MH'

October 31, 2004

Min Sun Harvey Supervisor Patent Examiner Art Unit 2828